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APPLICATION NO. FILING DATE		ING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/832,978 04/12/2001		1/12/2001	Hideo Kitagawa	itagawa 35.C15293 97.		
5514	7590	08/13/2003				
		LA HARPER &	EXAMINER			
30 ROCKEF NEW YORK				OLSEN, ALLAN W		
				ART UNIT	PAPER NUMBER	
				1763		
				DATE MAILED: 08/13/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

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		,	Applicati	on No.	Applicant(s)	
~•			09/832,9	78	KITAGAWA ET AL.	
	(	Offic Action Summary	Examin	· · · · · · · · · · · · · · · · · · ·	Art Unit	
			Allan W.		1763	
Perio	Th od for Re	e MAILING DATE of this communic ply	cation appears on th	e cover sheet with the d	correspondence address	
		ENED STATUTORY PERIOD FO	R REPLY IS SET 1	O EXPIRE 3 MONTH	S) FROM	
-	Extensions after SIX (6 If the period If NO period Failure to re Any reply re earned pate	ING DATE OF THIS COMMUNIC of time may be available under the provisions of MONTHS from the mailing date of this community for reply specified above is less than thirty (30) at for reply is specified above, the maximum state of the series of	of 37 CFR 1.136(a). In no evalunication.  The days, a reply within the starutory period will apply and will, by statute, cause the app	tutory minimum of thirty (30) day rill expire SIX (6) MONTHS from Dication to become ABANDONE	rs will be considered timely. the mailing date of this communicat D (35 U.S.C. § 133).	ion.
		sponsive to communication(s) file	ed on 12 April 2001			
	·	•	tb)⊠ This action is			
3	)∏ Sin	ce this application is in condition sed in accordance with the praction	for allowance excep ce under Ex parte 0	ot for formal matters, p Quayle, 1935 C.D. 11, 4	rosecution as to the meritals O.G. 213.	s is
•		of Claims				
4	<i>,</i> —	m(s) <u>1-20</u> is/are pending in the a				
_		Of the above claim(s) is/ard	e withdrawn from co	ensideration.		
		m(s) is/are allowed.				
		m(s) <u>1-20</u> is/are rejected.				
	•	m(s) is/are objected to.	:			
	)∐ Clai i <b>cation F</b>	m(s) are subject to restrict	tion and/or election i	equirement.		
		specification is objected to by the	Examiner.			
	<i>,</i> —	drawing(s) filed on is/are:		objected to by the Exa	miner.	
. •	•	plicant may not request that any obje				
11	-	proposed drawing correction filed				
	If a	ipproved, corrected drawings are req	uired in reply to this C	ffice action.		
12	)∐ The	oath or declaration is objected to	by the Examiner.			
Prior	ity unde	r 35 U.S.C. §§ 119 and 120				
13	)⊠ Ack	nowledgment is made of a claim	for foreign priority u	nder 35 U.S.C. § 119(a	a)-(d) or (f).	
	a)⊠ A	ll b)☐ Some * c)☐ None of:				
	1.⊠	Certified copies of the priority of	documents have be	en received.		
	2.	Certified copies of the priority of	documents have be	en received in Applicat	ion No	
	3. <u>□</u> * See t	Copies of the certified copies of application from the Internation attached detailed Office action	ational Bureau (PCT	Rule 17.2(a)).		
14)	☐ Ackn	owledgment is made of a claim fo	or domestic priority u	inder 35 U.S.C. § 119(	e) (to a provisional applica	ation).
	a) 🗌	The translation of the foreign lang	guage provisional a	oplication has been red	ceived.	
	nment(s)	<u> </u>	, <b>,</b> .	<b>33</b> -		
1)   2)	Notice of F	References Cited (PTO-892) Draftsperson's Patent Drawing Review (PT n Disclosure Statement(s) (PTO-1449) Pa			y (PTO-413) Paper No(s) Patent Application (PTO-152)	<u>.</u> .

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## **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

Claims 1-4, 6-8, 10-15 and 17-19 rejected under 35 U.S.C. 102(a) as being anticipated by U. S. Patent 6,037,255 issued to Hussein et al. (hereinafter, Hussein).

Hussein teaches a method of patterning an organic dielectric layer (103). Hussein teaches applying a patterned photoresist to a hard mask layer (104) that overlies the organic dielectric. Hussein teaches patterning the hard mask layer in order to expose a portion of the underlying dielectric so that the exposed portion of the dielectric can be removed by plasma etching. Hussein teaches a plasma etching gas that contains N₂ and H₂. Hussein teaches the organic layer is a polymer. Hussein teaches the use of low k dielectric polymers such as FLARE<sup>™</sup> and polyarylethers (column 2, line 57 - column 3, line 6). Hussein teaches using a hard mask material that that is the same as the barrier layer 102. Hussein teaches using titanium nitride as the barrier layer 102. Therefore, Hussein also teaches using titanium nitride as the hard mask material (column 3, lines 37-38 and column 2, lines 43-49). Hussein also discloses the utility of tantalum in the barrier/mask layers (column 3, line 63).

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claims 9 and 20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hussein.

As noted above, Hussein teaches the limitations of claims 1 and 11, upon which claims 9 and 20 respectively depend. Additionally it is noted that Hussein teaches that silicon nitride can be used as the hard masking layer.

Hussein does not teach an intermediate layer that is comprised of a metal or a metal compound and also an inorganic insulator in contact with the organic insulating film.

Specifically, Hussein does not teach an intermediate TiN/SiN bi-layer layer overlying the organic insulating film.

It would have been obvious to one skilled in the art, at the time the invention was made, to use a TiN/SiN bi-layer layer overlying the organic insulating film because Hussein teaches that each of Si N and TiN can be independently used and "[i]t is prima facie obvious to combine two compositions each of which is taught by the prior art to be useful for the same purpose, in order to form a third composition which is to be used for the very same purpose."

In re Kerkhoven 205 USPQ 1069 (CCPA 1980). Cites In re Susi 169 USPQ 423, 426 (CCPA 1971); In re Crockett 126 USPQ 186, 188 (CCPA 1960). See also Ex parte Quadranti 25 USPQ 2d 1071 (BPAI 1992).

Claims 5 and 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hussein as applied to claims 1 and 11 above and further in view of Suzuki et al. in EP 0880164 (hereinafter, Suzuki).

Hussein does not teach using a surface-wave interfered plasma.

Suzuki teaches using a surface-wave interfered plasma.

It would have been obvious to one skilled in the art to use a surface-wave interfered plasma because Suzuki teaches that this provides a uniform high density plasma over a large area. Additionally a higher quality plasma processing can be accomplished at lower temperatures over a wider pressure range (column 4).

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## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Allan Olsen whose telephone number is 703-306-9075. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Greg Mills, can be reached on 703-308-1633.

The examiner's Right-Fax (direct to desktop) phone number is 703-872-9684.

Alternatively, the general fax numbers for TC1700 are 703-872-9310 (non-after finals) and 703-872-9311(after-final).

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0661.

Allan Olsen, Ph.D. August 11, 2003

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